

Title (en)  
THERMAL DEVELOPING LIGHT-SENSITIVE MATERIAL

Publication  
**EP 0256820 A3 19890607 (EN)**

Application  
**EP 87307044 A 19870807**

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Abstract (en)  
[origin: EP0256820A2] There is disclosed a thermal developing light-sensitive material comprising a support and, provided thereon, photographic structural layers comprising at least one layer containing light-sensitive silver halide, said photographic structural layer comprising a compound represented by general formula (1); Formula (1) X1 - L1 - A wherein X1 represents a residual group of a photographic restrainer, L1 is a mere bonding hand or a divalent group and A is selected from the group consisting of a hydrogen atom, an amino group, a hydroxyl group, a carboxyl group or a salt thereof, a sulfo group or a salt thereof and a sulfin group or a salt thereof; and a compound represented by general formula (2); Formula (2) X2 - L2 - B wherein X2 represents a residual group of a photographic restrainer, L2 is a divalent group and B is a ballast group.

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**G03C 1/02**

IPC 8 full level  
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[XPL] EP 0218385 A2 19870415 - KONISHIROKU PHOTO IND [JP]

Cited by  
US5441851A; US5409809A; EP1420292A1; EP1422551A1; US6902880B2; US6908731B2; US7060655B2

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